

# Resource Summary Report

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## Horiba: CS-100 F4 Multi-point Chemical Solution Monitor

RRID:SCR\_020041

Type: Tool

### Proper Citation

Horiba: CS-100 F4 Multi-point Chemical Solution Monitor (RRID:SCR\_020041)

### Resource Information

**URL:** [https://www.horiba.com/en\\_en/products/detail/action/show/Product/cs-100f4-650/](https://www.horiba.com/en_en/products/detail/action/show/Product/cs-100f4-650/)

**Proper Citation:** Horiba: CS-100 F4 Multi-point Chemical Solution Monitor (RRID:SCR\_020041)

**Description:** Multi point chemical solution monitor with multipoint chemical measurement into single units used in etching and cleaning processes for semiconductor manufacturing.

**Resource Type:** instrument resource

**Keywords:** Horiba, Multi-point Chemical Solution Monitor, Instrument, Resource Equipment, Equipment, USEDit,

**Availability:** Commercially available

**Resource Name:** Horiba: CS-100 F4 Multi-point Chemical Solution Monitor

**Resource ID:** SCR\_020041

**Alternate IDs:** Model\_Number\_CS\_100\_F4

**Record Creation Time:** 20220129T080348+0000

**Record Last Update:** 20260725T190921+0000

### Ratings and Alerts

No rating or validation information has been found for Horiba: CS-100 F4 Multi-point Chemical Solution Monitor.

No alerts have been found for Horiba: CS-100 F4 Multi-point Chemical Solution Monitor.

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## Data and Source Information

**Source:** [SciCrunch Registry](#)

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## Usage and Citation Metrics

We have not found any literature mentions for this resource.